

L8 ANSWER 1 OF 3 CAPLUS COPYRIGHT 2008 ACS on STN
 AN 2000:181103 CAPLUS
 DN 132:223592
 ED Entered STN: 21 Mar 2000
 TI Polyamide compositions for bonding of electronic parts at high temperature, and solvent- and heat-bonding methods using the compositions
 IN Nakanishi, Takashi; Sugiyama, Masahide
 PA Tomoeogawa Paper Co., Ltd., Japan
 SO Jpn. Kokai Tokkyo Koho, 10 pp.
 CODEN: JKXXAF
 DT Patent
 LA Japanese
 IC ICM C09J177-06
 ICS C08L077-06; H01B003-30; H01F005-06
 CC 38-3 (Plastics Fabrication and Uses)
 Section cross-reference(s): 76
 FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI JP 2000080344	A	20000321	JP 1998-267322	19980904 <--
JP 3523082	B2	20040426		
PRAI JP 1998-267322		19980904		

CLASS

PATENT NO.	CLASS	PATENT FAMILY CLASSIFICATION CODES
JP 2000080344	ICM	C09J177-06
	ICS	C08L077-06; H01B003-30; H01F005-06
	IPCI	C09J0177-06 [ICM,7]; C08L0077-06 [ICS,7]; H01B0003-30 [ICS,7]; H01F0005-06 [ICS,7]
	IPCR	H01F0005-06 [I,C*]; H01F0005-06 [I,A]; C08L0077-00 [I,C*]; C08L0077-06 [I,A]; C09J0177-00 [I,C*]; C09J0177-06 [I,A]; H01B0003-30 [I,C*]; H01B0003-30 [I,A]

AB The compns. contain phenolic OH-containing aromatic polyamides and linear polyamides having methoxymethylated amide groups. A solution containing 50 parts alc.-soluble 5-hydroxyisophthalic acid-Kayabond C 300 [bis(4-amino-3,5-diethylphenyl)methane] copolymer (intrinsic viscosity 0.60 dL/g at 30°) and 50 parts FR-101 (30% methoxymethylated linear polyamide) was applied on 2 sheets of Cu foil and they were adhered by heat-bonding or solvent-bonding method to show both 80% adhesive strength retention at 180° compared with adhesive strength at 25°.
 ST heat resistance adhesive methoxymethylated polyamide electronic; solvent heat bonding electronic part polyamide; phenolic hydroxy isophthalic acid aminodiethylphenylmethane copolymer adhesive electronic
 IT Polyamides, uses
 RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)
 (aromatic; heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)
 IT Adhesion, physical
 Electric apparatus
 Electric conductors
 (heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)
 IT Adhesives
 (heat-resistant; heat-resistant polyamide compns. for solvent- and

heat-bonding of elec. parts)

IT Polyamides, uses
RL: POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); USES (Uses)
(linear, methoxymethylated; heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

IT Alcohols, uses
RL: NUU (Other use, unclassified); USES (Uses)
(solvents; heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

IT 7440-50-8, Copper, miscellaneous
RL: MSC (Miscellaneous)
(foil; heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

IT 146187-38-4P, 3,4'-Diaminodiphenyl ether-5-hydroxyisophthalic acid copolymer 146584-70-5P, 3,4'-Diaminodiphenyl ether-5-hydroxyisophthalic acid copolymer, sru 180579-38-8P, 5-Hydroxyisophthalic acid-Kayabond C 300 copolymer 180579-39-9P, 5-Hydroxyisophthalic acid-Kayabond C 300 copolymer, sru 180579-40-2P, 5-Hydroxyisophthalic acid-Kayabond C 300-isophthalic acid copolymer 180579-41-3P, Curehard MED-5-hydroxyisophthalic acid copolymer 180579-45-7P 223132-36-3P, 5-Hydroxyisophthalic acid-Kayabond C 400 copolymer 232585-23-8P
RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)
(heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

IT 25035-02-3, Fine Resin FR 104 112353-50-1, Fine Resin FR 101
261621-50-5, Fine Resin FR 105
RL: POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); USES (Uses)
(heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

IT 64-17-5, Ethanol, uses
RL: NUU (Other use, unclassified); USES (Uses)
(solvent; heat-resistant polyamide compns. for solvent- and heat-bonding of elec. parts)

RN 7440-50-8
RN 146187-38-4P
RN 146584-70-5P
RN 180579-38-8P
RN 180579-39-9P
RN 180579-40-2P
RN 180579-41-3P
RN 180579-45-7P
RN 223132-36-3P
RN 232585-23-8P
RN 25035-02-3
RN 112353-50-1
RN 261621-50-5
RN 64-17-5

L8 ANSWER 2 OF 3 WPIX COPYRIGHT 2008 THOMSON REUTERS on STN
AN 2000-286909 [25] WPIX
DNC C2000-087034 [25]
DNC N2000-216118 [25]

TI Resin composition for adhesion of electronic device - comprises aromatic polyamide with at least phenolic hydroxyl, and linear polyamide resin
DC A23; A85; G03; L03; V02; V04; X12
IN NAKANISHI T; SUGIYAMA H
PA (TOMO-C) TOMOEGAWA SEISHISHO KK

CYC 1
 PI JP 2000080344 A 20000321 (200025)* JA 10[0] <--
 JP 3523082 B2 20040426 (200428) JA 10
 ADT JP 2000080344 A JP 1998-267322 19980904; JP 3523082 B2 JP
 1998-267322 19980904
 FDT JP 3523082 B2 Previous Publ JP 2000080344 A
 PRAI JP 1998-267322 19980904
 IPCR C08L0077-00 [I,C]; C08L0077-06 [I,A]; C09J0177-00 [I,C]; C09J0177-06
 [I,A]; H01B0003-30 [I,A]; H01B0003-30 [I,C]; H01F0005-06 [I,A];
 H01F0005-06 [I,C]
 AB JP 2000080344 A UPAB: 20060116
 NOVELTY - Resin composition comprises aromatic polyamide with at least
 phenolic hydroxyl, and linear polyamide resin in which a part of amide is
 methoxymethylated.
 DETAILED DESCRIPTION - Resin composition comprises aromatic polyamide with
 at least phenolic hydroxyl and linear polyamide resin in which a part of
 amide is methoxymethylated.
 An INDEPENDENT CLAIM is also included for method of adhesion using the
 resin composition comprising applying and drying the resin composition to
 the surface of an adherend, forming resin film on the surface of the
 adherend, heating the film and putting another adherend to the surface of
 the film.
 USE - The resin composition is useful for adhesion of electronic
 devices, preferably for insulating a wire used for coils.
 ADVANTAGE - The resin composition exhibits improved adhesiveness and
 insulating capacity and less lowers the adhesive property at higher
 temperature.
 MC CPI: A05-F01E2; A12-E02A; A12-E07C; G03-B02E; L03-A01B3; L03-B02F;
 L04-C17D
 EPI: V02-G02B1; V04-X01B; X12-C01B; X12-E02B
 L8 ANSWER 3 OF 3 JAPIO (C) 2008 JPO on STN
 AN 2000-080344 JAPIO
 TI RESIN COMPOSITION AND BONDING METHOD USING THE SAME
 IN NAKANISHI TAKAYUKI; SUGIYAMA HITOCHIDE
 PA TOMOE GAWA PAPER CO LTD
 PI JP 2000080344 A 20000321 Heisei
 AI JP 1998-267322 (JP10267322 Heisei) 19980904
 PRAI JP 1998-267322 19980904
 SO PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined Applications, Vol. 2000
 IC C09J177-06
 ICS C08L077-06; H01B003-30; H01F005-06
 AB PROBLEM TO BE SOLVED: To improve heat resistance, insulating properties
 and adhesiveness at a high temperature of a resin composition by blending
 an aromatic polyamide resin having a phenolic hydroxide group and a
 specific linear polyamide resin.
 SOLUTION: An aromatic polyamide resin having a phenolic hydroxide group
 which resin comprises 5-100 mol% of a repeating unit of formula I and 0-95
 mol% of a repeating unit of formula II is obtained by reacting an aromatic
 diamine compound having at least one alkyl group on the ortho-position of
 the terminal amino aryl group and an aromatic dicarboxylic acid having a
 phenolic hydroxide group. 1-70 pts.weight of the aromatic polyamide resin is
 blended with an alcohol-soluble linear polyamide resin whose amide groups
 are partially di-methylated in the amount such that the total be 100
 pts.weight In the formulas, Ar is a bivalent aromatic group, R and R' are
 each H or a 1-4C alkyl but both are not H simultaneously, R2 is a 1-3C
 alkylene which may be substituted by F, and (n) is 1 or 2.
 COPYRIGHT: (C)2000,JPO

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